

**Amendments to the Specification**

Please replace the title of the application with the following title:

**A METHOD FOR DEPOSITING A PLURALITY OF LAYERS ON A SUBSTRATE**

Please replace the abstract with the following:

**Abstract**

~~The invention relates to a~~ A method for depositing a plurality of layers on a substrate using gaseous starting materials, whereby the layers are deposited in one single process chamber in successive process steps. The gas phase composition and/or the substrate temperature is varied without the process chamber being opened in the interim, in such a way that layers of different quality can be deposited successively in one deposition chamber.